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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/915,618	07/26/2001	Yoshikazu Nakayama	57A 3127	6828
. 75	90 03/04/2003			
KODA & ANDROLIA			EXAMINER	
Suite 3850 2029 Century Park East Los Angeles, CA 90067-3024			DUDDING, ALFRED E	
			ART UNIT	PAPER NUMBER
			2853	
			DATE MAILED: 03/04/2003	\bigcirc

Please find below and/or attached an Office communication concerning this application or proceeding.

PTO-90C (Rev. 07-01)

Application No. Office Action Summary Examiner Art Unit Alfred E. Dudding 2853 The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed						
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 Extensions of time may be available under the provisions of 37 CFR 1.136(a). If no event, however, may a tepty of timely made after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). 						
1) Responsive to communication(s) filed on <u>26 July 2001</u> .						
2a) ☐ This action is FINAL . 2b) ☑ This action is non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims						
4) Claim(s) 1-7 is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1,4,6 and 7</u> is/are rejected.						
7)⊠ Claim(s) <u>2,3 and 5</u> is/are objected to.						
8) Claim(s) are subject to restriction and/or election requirement.						
Application Papers						
9) The specification is objected to by the Examiner. 10) The drawing(s) filed on <u>26 July 2001</u> is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) ☐ All b) ☐ Some * c) ☐ None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.						
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).						
a) ☐ The translation of the foreign language provisional application has been received. 15)☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.						
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 4) Interview Summary (PTO-413) Paper No(s) 5) Notice of Informal Patent Application (PTO-152) 6) Other:						

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DETAILED ACTION

Drawings

1. Figure 14 displays only a black background with a label "500nm". It is requested that the applicant submit a replacement for Figure 14 that shows claimed details.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.
- 3. Claims 1, 4/(1,2), 6, and 7 are ejected under 35 U.S.C. 102(a) as being anticipated by Yano et al. (U.S. 6,166,386 A).

Yano et al. discloses a lithographic method to form groove-form patterns on a sample surface comprising the steps of causing a tip end of a probe needle to contact a surface of a sample either continuously or intermittently, Figure 8, element 2401 (probe), Column 2, lines 24 25, said probe needle being an ultra-fine probe needle with a nano-size tip end diameter, applying a voltage across said probe needle and sample, and causing said probe needle to move while removing a substance that makes said sample at a probe needle contact area by an application of said voltage, Column 17, lines 249 – 53. Yano et al. discloses that the probe holder is a cantilever for an AFM (atomic force microscope), Figure 9, element 2402 (cantilever), and Column 1, lines 28 – 31. Yano et al. discloses a lithographic method wherein said sample is a lithographable matter including an organic film, other organic matter and an inorganic matter,

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and a voltage is applied across said probe needle and said organic film so that said probe needle is used as a cathode., Column 4, lines 37 – 40, Column 16, lines 28 – 30, and Figure 9, elements 24-5 (polyimide film), element 2406 (gold film).

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 6. Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over Yano et al. (U.S. 6,166,386 A) in view of Hiroka et al. (U.S. 4,464,460 A).

Yano et al. fail to teach the claimed invention of. a lithographic method wherein said organic film is a polysilane film.

Hiraoka et al. discloses the use of a polysilane film on a substrate, Column 4, lines 6 – 14.

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It would have been obvious to one of ordinary skill in the art at the time the invention was made to use a polysilane film on a substrate in order to etch said film without the use of a vacuum. The suggestion/motivation is given by the '460 patent Column 1, lines 46 – 47, a process for making an imaged oxygen-reactive ion etch barrier.

Allowable Subject Matter

- 7. Claims 2, 3, and 5/(1, 2) are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- a. A search of prior art did not cite a lithographic method wherein said ultra-fine probe needle is a nanotube probe that is formed by fastening a base end portion of a nanotube to a holder with a tip end portion of said nanotube being caused to protrude from said holder as claimed in the limitations of claims 2 and 3.
- **b**. A search of prior art did not cite a lithographic method wherein a groove width of and a groove depth of said groove of said groove-form pattern are controlled by adjusting a scanning speed of said probe needle and an applied voltage, as claimed in the limitations of claim 5/(1, 2).

Conclusion

8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Bridger et al. (U.S. 6,078,055 A) discloses a lithographic etching apparatus and a method using a 20 nm diameter probe, Figure 3, Abstract, lines 4 – 11. Bridger et al. fail to tech the use of a nanotube as the probe.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Alfred Dudding whose telephone number is (703) 308-6082. The examiner can normally be reached on Monday-Friday from 9:30 AM to 6:00 PM. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Barlow Jr., AU 2853, can be reached at (703) 308-3126. The fax phone numbers for this Group are (703) 305-3432, (703) 305-3431, (703) 308-7382, (703) 308-7724, and (703) 308-7722.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the group receptionist whose telephone number is (703) 308-0956.

ANH T.N. VO

13/01/03

Alfred Dudding

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